

	Type	L #	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r D e f i n i t i o n	E r r o r s
9	BRS	L50	25	43 and 15 and 36 and (22 or 29)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:25			0
10	BRS	L64	22	50 and etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:26			0
11	BRS	L71	1	43 with (replac\$3 or substitut\$3) with ("C.sub.4 F.sub.8" or C4F8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 11:56			0
12	BRS	L78	459	36 same etch\$3 same (replac\$3 or substitut\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 12:49			0
13	BRS	L85	88	36 with etch\$3 with (replac\$3 or substitut\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 12:55			0
14	BRS	L92	432	36 with etch\$3 with ((noble or carrier or diluent) adj gas)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 12:57			0

	Type	L #	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r s	E r r o r s
1	BRS	L1	127	"C.SUB.4 F.SUB.6"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:02			0
2	BRS	L8	29	C4F6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:01			0
3	BRS	L15	3051	"CH.SUB.2 F.SUB.2" or CH2F2 or difluoromethane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:10			0
4	BRS	L22	13784	"CHF.sub.3" or CHF3 or trifluoromethane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:04			0
5	BRS	L29	15200	"CF.sub.4" or CF4 or tetrafluoromethane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:05			0
6	BRS	L36	595807	Ar or argon or He or helium or Xe or xenon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 12:48			0
7	BRS	L43	156	1 or 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 11:55			0
8	BRS	L57	0	43 with 15 with 36 with (22 or 29)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 10:12			0